



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#14/Amend B  
Amend  
10/23/02

In re the Application of

Eiji NATORI

Group Art Unit: 2813

Application No.: 09/819,688

Examiner: D. Hogan

Filed: March 29, 2001

Docket No.: 109120

For: METHOD AND DEVICE FOR MANUFACTURING CERAMICS,  
SEMICONDUCTOR DEVICE AND PIEZOELECTRIC DEVICE

RECEIVED  
OCT 15 2002  
TECHNOLOGY CENTER-2800

AMENDMENT UNDER 37 C.F.R. §1.111

Director of the U.S. Patent and Trademark Office  
Washington, D.C. 20231

Sir:

In reply to the April 10, 2002 Office Action, please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claim 14 without prejudice to or disclaimer of the subject matter contained therein.

Please replace claim 1 as follows:

1. (Amended) A method for manufacturing ceramics comprising a step of forming a ceramic film on a substrate by mixing a fine particle of a raw material species which becomes at least part of raw materials for ceramics with an active species, and feeding the mixed fine particle and active species to the substrate, wherein the ceramic film is formed by an LSMCD process or a misted CVD process.

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